



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kirk Martin
Assignee: Nisene Technology Group
Title: Method and Apparatus for Etching a Semiconductor Die
Serial No.: 09/902,931 Filed: July 10, 2001
Examiner: Vinh, Lan Group Art Unit: 1765
Docket No.: M-11706 US
(NTG-P101)

San Jose, California
February 10, 2004

Mail Stop Issue Fee
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

SUBMISSION OF FORMAL DRAWINGS

Dear Sir:

Applicant submits six (6) sheets of formal drawing, consisting of Figures 1, 2, 3, 4, 5, 6, 7, and 8, in the above-named application. If there are any questions regarding these drawings, please call the undersigned at (408) 382-0480.

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on Feb. 10, 2004.

Carmen C. Cook
Attorney for Applicant(s)

2/10/2004
Date of Signature

Respectfully submitted,

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